Disturb Testing in Flash Memories

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Executive Summary

2Gb NAND flash devices were tested for sensitivity to both program and read disturb conditions. This disturb testing is part of the overall reliability evaluation of these devices for use on NASA missions. Radiation evaluation for these devices has already been documented [Irom].

Disturb testing is designed to study the robustness of the data storage of the flash cells when the state of a nearby cell is being changed, either through programming or reading. A disturb failure means that the initial (and expected) state of the cell has been changed (disturbed) to the opposite state as a result of programming or reading the nearby cells. Disturb failures are usually soft failures that require additional device commands to repair.

Flash manufacturers acknowledge disturb failures can occur on their devices and try to provide users with guidance on how to address them. For the high reliability nature of NASA missions, a quantitative understanding of the possible degree of disturb failures is required. Such quantitative understanding will guide device screening and procurement requirements as well as possible system mitigation implementations.

No specific disturb failures were noted on the testing done for this report. However, inconsistent behavior in flash memory bad blocks was observed. Block locations that were initially identified as bad by the manufacturer performed correctly as the device began to be exercised. These locations remained robust even as the device was stressed over time and temperature.

Other cells marked as good by the manufacturer began to degrade under this exposure to time and temperature. The associated failure rate with this degradation is 100X higher than predicted by the manufacturer’s data. At this time, it is unknown why such a high failure rate was observed.

The existence of this much higher failure rate and inconsistency in manufacturer-defined bad and good blocks means that NASA must individually screen, characterize, and qualify any and all NAND flash devices that it intends to use for spacecraft applications.
Introduction

Non-volatile memory technology as defined by NAND architecture flash memory continues to lead the process scaling and device shrinking efforts of the entire integrated circuit industry. 45-nm technology nodes are now producing commercial 32Gb devices. These latest 32Gb devices are pioneering new charge trapping memory cell technologies using metal gates and high-k dielectric materials. These cells are called TANOS and consist of tantalum-nitride, aluminum oxide (high k material), nitride, oxide, and silicon. Such high-density memories continue to revolutionize commercial electronics in terms of new high-speed data architectures and significant reductions in overall power and weight consumption.

In stark contrast, nearly all science-based interplanetary and earth-orbiting NASA spacecraft are still designing in and around mid-1980s-level non-volatile technology with 1Mb Electrically Erasable Read-Only Memory (EEPROM) devices. NASA has typically shunned the use of modern flash devices because of radiation and reliability concerns due to the commercial-off-the-shelf (COTS) nature of the NAND flash technology. Given the significant potential increases in overall system capability these modern flash devices could bring to NASA missions, it is important to continue to investigate these devices. This report will investigate certain portions of the reliability performance of NAND flash devices, specifically the disturb properties. Understanding the possible limitations such new non-volatile memory technology presents to NASA is the goal of this report.

Review of Flash Memory Technology

There are two primary types of NAND flash technology. Historically, the majority of the market was served by single-level cell (SLC) NAND. Beginning in 2006, the market has migrated to multi-level cell (MLC) NAND, and by the end of the year, there was a nearly even distribution in shipments between the two types of cells [Cooke]. From 2007 and on, it is expected that the majority of shipments will be MLC NAND. However, SLC will retain much of the market for high-performance, high-reliability applications. SLC is the style device that will be examined for this report.
From a commercial point-of-view, MLC NAND tends to be used in low-cost consumer applications, including media players, MP3 devices, media cards, and USB flash drives. Meanwhile, professional products and solid state drives (SSDs) demand the higher performance and reliability of SLC NAND flash memory.

Figures 1 and 2 illustrate the comparative differences between MLC and SLC NAND flash cells, respectively. SLC NAND stores two binary states (either a binary 1 or a binary 0) in a single cell, whereas MLC NAND can store four states: 00, 01, 10, and 11. There is considerably more design margin with SLC, which leads to greater robustness, reliability, and endurance compared to MLC.
Table 1 shows the differences between the MLC and the SLC devices.

**Table 1. Differences between MLC and SLC Flash Devices [Cooke]**

<table>
<thead>
<tr>
<th>Features</th>
<th>MLC</th>
<th>SLC</th>
</tr>
</thead>
<tbody>
<tr>
<td>Bits per cell</td>
<td>2</td>
<td>1</td>
</tr>
<tr>
<td>Voltage</td>
<td>3.3V</td>
<td>3.3V, 1.8V</td>
</tr>
<tr>
<td>Data width (bits)</td>
<td>x8</td>
<td>x8, x16</td>
</tr>
<tr>
<td>Architecture</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Number of planes</td>
<td>2</td>
<td>1 or 2</td>
</tr>
<tr>
<td>Page size</td>
<td>2,112–4,314 bytes</td>
<td>2,112 bytes</td>
</tr>
<tr>
<td>Pages per block</td>
<td>128</td>
<td>64</td>
</tr>
<tr>
<td>Reliability</td>
<td></td>
<td></td>
</tr>
<tr>
<td>NOP (partial page programming)</td>
<td>1</td>
<td>4</td>
</tr>
<tr>
<td>ECC (per 512 bytes)</td>
<td>4+</td>
<td>1</td>
</tr>
<tr>
<td>Endurance (ERASE/PROGRAM cycles)</td>
<td>&lt;10K</td>
<td>&lt;100K</td>
</tr>
<tr>
<td>Array Operations</td>
<td></td>
<td></td>
</tr>
<tr>
<td>R (READ operation)</td>
<td>50μs</td>
<td>25μs</td>
</tr>
<tr>
<td>PROG (PROGRAM operation)</td>
<td>600-900μs</td>
<td>200-300μs</td>
</tr>
<tr>
<td>BERS (ERASE operation)</td>
<td>3ms</td>
<td>1.5-2ms</td>
</tr>
</tbody>
</table>

Table 1 shows a significant reduction by a factor of 10 in the endurance capabilities of MLC-based flash. Having less than 10K Erase/Program cycles makes the MLC designs a very real reliability risk for high reliability space missions. There is also a 4X increase in the amount of Error Correction Coding (ECC) required to use the MLC. Such overhead would negatively impact space missions with strict real-time protocol system requirements.

Figure 3 shows a simple NAND cell layout. The unit cells are connected sequentially. At one end is the bit-line connection and at the other end is the select/source-line connection. The cells resemble a NAND gate. This layout prevents cells from being read and programmed individually. Cells connected in series must be read in series.
An example cross-section through bit-line contacts is shown in Figure 4.

**Figure 4. Cross Section of 2Gb Flash Cell**

The overall architecture of the NAND flash device is shown in Figure 5. Here it can be seen that a page is defined as cells connected with the same word line. Sixty-four (64) pages are shown to make up one block. This example has 1024 blocks.

**Figure 5. Schematic Architecture of NAND Flash Device**
NAND Flash Memory Operation

The NAND flash does not have dedicated address lines. It is controlled using an indirect input/output (I/O)-like interface. Commands and addresses are sent through an 8-bit bus to an internal command and address register. Because of this indirect interface, it is generally not possible to “boot” from a NAND without using a dedicated state machine or controller. The advantage of an indirect interface is that device pin-out does not change with different device densities.

Figure 6 shows a typical 2Gb, 2K-page SLC NAND architecture. This is the type of device that has been chosen for detailed testing for this paper. The device is comprised of 2,048 independent blocks. A block is the smallest erasable entity. Each block contains 64 pages that consist of 2,112 bytes—2,048 bytes of data and 64 bytes of spare area for ECC and other software overhead. A page is the smallest programmable unit. The device includes an I/O shift register, known as the cache register, which is used for double buffering. Data are shifted into and out of the cache register byte-by-byte. When a READ operation is requested, the array is accessed and the data are loaded into the cache register then shifted out. For a programming operation, data are shifted into the registers before ultimately programming the data into the array.

![Figure 6. Architecture of a 2Gb NAND Flash](image_url)
NAND Flash Errors Modes

All NAND flash devices have finite lifetimes and will eventually wear out with repeated use. Each block is an independent unit of storage, and can be erased and reprogrammed without affecting the lifetime of the other blocks. Good blocks can be erased and programmed between 100,000 and 1,000,000 times before end of life occurs.

The primary wear out mechanism is usually an excess trapped charge in the oxide of the memory cell. The net effect of this charge is to increase erase times until an internal timer times out. This is known as the Narrowing Effect. The programming times as seen by the user tend to decrease slightly with increasing number of total write/erase cycles. This means device lifetime is usually not characterized by a program failure. A program (or page program) failure would indicate a much more severe device failure.

Figure 7 shows a cross-section drawing of a flash cell being programmed and erased. The top left cell is programmed as electrons are accumulated on the floating gate. The top right cell is erased to a “1” state as excess electrons are moved to the substrate.

Figure 7. Write/Erase Conditions for Flash Cell
The bottom left cell indicates excessive write/erase conditions. Finally, the bottom right cell shows possible damage in the oxide that forms a leakage path due to trapped charge. This damage leads to bit, page or block fail.

Figure 8 shows a normal flash read. A bit line is pre-selected and the select transistor is turned on. Threshold voltages are below a bias value. The application of $V_{\text{bias}}$ to selected pages enables them to turn on. The cell charge is then placed on the bit line. The sense amp (S/A) then senses the voltage condition and determines if the cell had a “1” or a “0.”

Cell failures can result when the threshold voltage becomes too high, and thus, the bias voltage needed to turn on the cell is never reached.

**Disturb Errors**

Program disturb occurs when a bit is unintentionally programmed from a “1” to a “0” during a page-programming event. This bit error may occur either on the page being programmed or on another page in the block. Bias voltage conditions in the block during the page programming can cause a small amount of current to tunnel into nearby memory cells. Repeated partial page programming attempts will continue to aggravate this condition.
It is known that program/erase cycling of flash memories induces a degradation of the tunnel oxide insulating property usually referred to as Stress-Induced Leakage Current (SILC). Read disturb can be related to SILC conditions [Yang].

With a condition of SILC, a read disturb can manifest itself as affecting cells in an addressed word-line. This results in electron injection through the tunnel oxide in the floating gate of erased cells during read operation. Read disturb can also be present in Flash memory with a weak tunnel oxide quality [Tanduo].

Error modes for NAND include program disturb, read disturb, and endurance. Each error-mode issue is well understood and easily addressed. It is mandatory to use the minimum ECC specified for reliable systems. Using more robust ECC schemes will provide additional system reliability. In some cases, program and read operations may cause electrons to move to or from other cells within the block.

To reduce program disturb, it is recommended to sequentially program pages in a block. It is also important to minimize partial-page programming operations in SLC devices, and it is mandatory to restrict page programming to a single operation in MLC.

Read disturb can be reduced by minimizing excessive reads. The rule of thumb is no more than 1 million READ cycles (per block) for SLC, and a maximum of 100,000 READ cycles for MLC. If possible, the data should be read equally from pages within the block. If it is necessary to exceed the “rule-of-thumb” cycle count, then the data should be moved to another block and the original block should be erased. Each erase resets the read disturb cycle count.

SLC devices are specified at 100,000 PROGRAM/ERASE cycles. Also, it is possible to meet the extended data retention by limiting PROGRAM/ERASE cycles in blocks that require long retention. In this way, infrequently cycled blocks will have longer retention and frequently cycled blocks will have shorter retention.
It is important to employ wear leveling, which ensures that data are written equally to all good blocks rather than cycling the same block. Wear leveling provides additional benefits on SLC devices where blocks can support up to 100,000 PROGRAM/ERASE cycles, but it is imperative on MLC devices where blocks can typically support less than 10,000 cycles.

If a block were to be erased and programmed each minute, the 10,000 cycling limit would be exceeded in just 7 days (60 x 24 x 7 = 10,080 cycles). Consider an 8Gb MLC device that contains 4,096 independent blocks. Using the previous example and distributing the cycles over all 4,096 blocks, each block would be programmed fewer than three times (versus the 10,800 cycles involved with cycling the same block). If perfect wear leveling was provided on a 4,096-block device every minute of every day, it would take 77 years to reach the specified PROGRAM/ERASE cycle limit for the device.

**Bad Blocks**

Because NAND flash devices were designed to serve as low cost solid-state mass storage, Institute of Electrical and Electronics Engineers (IEEE) standards have made allowance for the existence of bad blocks. Allowing for the existence of bad blocks increases effective chip yield and helps lower cost. The existence of bad blocks does not affect good blocks because each bad block is independent and is individually isolated from the bit lines by block select transistors.

However, a bad block table must be maintained for the system to be able to identify areas of the device to not use. During manufacturing test and screening, flash manufacturers mark bad blocks by storing 00h in a specific byte for each page. These bad blocks are determined by extensive pattern testing over temperature and voltage extremes. In a brand new device, any block that does not read out a 1’s pattern (FFh) is considered bad.

Bad blocks can result from a number of different problems, including decoder failure, word line failure, and memory cell failure.
Device Programming Details

The goal of this particular experiment was to characterize 2Gb SLC NAND flash devices for their sensitivity to conditions designed to create disturb events in the part. The devices tested were Micron MT29F08AACWPET. All programming and testing was done at Semiconductor Solutions, Inc. in Sparks, Nevada [Semiconductor Solutions, Inc.]

The testing of the parts was divided into three basic areas:

1. DC/AC Characterization
2. Bad Block and Program/Erase Characterization
3. Disturb Testing

Programs 1 and 2, listed below, show the details of the DC and AC parametric testing.

Program 1—DC Parametric Test
a. Sequential read current [I_{CC1}] \{t_{re}=30ns; CE#=V_{IL}; I_{OUT}=0ma\}
b. Program current [I_{CC2}]
c. Erase current [I_{CC3}]
d. Standby current (TTL) [I_{SB1}] \{CE#=V_{IH}; WP#=0V/V_{CC}\}
e. Standby current (CMOS) [I_{SB2}] \{CE#=V_{CC}-0.2V; WP#=0V/V_{CC}\}
f. Input leakage current [I_{LI}] \{V_{IN}=0V\text{ to } V_{CC}\}
g. Output leakage current [I_{LO}] \{V_{OUT}=0V\text{ to } V_{CC}\}
h. Input high voltage \{V_{IH}\} \{I/O[7:0], CE#, CLE, ALE, WE#, RE#, WP#, R/B#\}
i. Input low voltage \{V_{IL}\} \{all inputs\}
j. Output high voltage \{V_{OH}\} \{I_{OH}=-100ua\}
k. Output low voltage \{V_{OL}\} \{I_{OL}=+100ua\}
l. Output low current \{I_{OL}(R/B#)\} \{V_{OL}=0.1V\}

Program 2—AC Characteristics (command, data, and address input)
a. ALE to data start \{t_{ADL}\}
b. ALE hold time \{t_{ALH}\}
c. ALE setup time \{t_{ALS}\}
d. CE# hold time \{t_{CH}\}
e. CLE hold time \{t_{CLH}\}
f. CLE setup time \{t_{CLS}\}
g. CE# setup time \{t_{CS}\}
h. Data hold time \{t_{DH}\}
i. Data setup time \{t_{DS}\}
j. Write cycle time \{t_{WC}\}
Every Micron NAND flash will have bad blocks as shipped. Micron’s specification is that each Flash will have a minimum of 2,008 good blocks out of every 2,048 total available blocks. A bad block is defined as a block that contains 1 or more bad bits. Micron requires that bad block management software be implemented to reliably use the NAND flash in normal operation.

Instead of avoiding bad blocks, this experiment was set up to explicitly identify bad blocks and then incorporate them into active device testing. Essentially a bad block offers an opportunity to see if that particular degraded cell can be further and possibly more easily degraded. The degraded cell may also act as a “defect site,” allowing an increase in the probability of degrading its surrounding good cells. Being able to degrade surrounding and nearest neighbor cells is at the heart of disturb testing.

A bad block has at least one bad bit, and many bits that are still considered good (even though they are excluded from normal operation because they share logical address space with the known bad bit[s]). The reason for the bad bit is unknown. It could be a defect local to that particular cell or a more global defect that affects a neighborhood of cells. Such defective cells may be more sensitive to disturb conditions.

The basic hypothesis of this experiment is that disturb failures will occur more often in the bad block areas than disturb failures in the initially good (or non-bad) blocks.

The following test describes the bad block testing sequence.

Program 3—Bad Block Table Generation
   a. Identify bad blocks
   b. Read the spare address on the first two pages of each block
   c. Do this prior to performing any programming or erase operations.
   d. Record all addresses that have data in them different than FFh in the Bad Block Table
Once the bad block table has been generated from virgin parts, then the program erase characteristics need to be evaluated. This is done with Programs 4 and 5 listed below.

**Program 4—Program/Erase/Read—AAh**
- a. Program AAh to all memory locations
- b. Record program time duration for each page
- c. Read all memory locations
- d. Record read time duration for each page
- e. Identify the address location of each error detected
- f. Erase all memory locations
- g. Record erase time duration for each block
- h. Repeat steps (a) through (g) above 10 times

**Program 5—Program/Erase/Read—55h**
- a. Program 55h to all memory locations
- b. Record program time duration for each page
- c. Read all memory locations
- d. Record read time duration for each page
- e. Identify the address location of each error detected
- f. Erase all memory locations
- g. Record erase time duration for each block
- h. Repeat steps (a) through (g) above 10 times

There were three custom designed programs to evaluate disturb testing. The first one of these programs was to compare bad blocks vs. good blocks. In this test, the erase and program performance of good and bad blocks was determined. The specific program is listed in Program 6.

**Program 6—Bad Block vs. Good Block Test**
- a. Perform 1,000 ‘block erase’ operations on each bad block in the Bad Block Table generated in Program 3; after each ‘block erase,’ perform a ‘read status’ operation
- b. Perform 1,000 ‘block erase’ operations on the known good blocks (not in the Bad Block Table); after each ‘block erase,’ perform a ‘read status’ operation
- c. Perform 1,000 ‘program page’ operations on each page of each bad block in the Bad Block Table generated above; after each ‘program page,’ perform a ‘read status’ operation
- d. Perform 1,000 ‘program page’ operations on each page of the known good blocks (not in the Bad Block Table); after each ‘program page,’ perform a ‘read status’ operation

Disturb testing was performed for both program disturb as well as read disturb. Both bad and good blocks were used in this disturb testing. The disturb testing details are listed in Programs 7 and 8.
Program 7—Program Disturb Testing
   a. Using AAh data, perform ‘partial page program’ operations on all blocks (good or bad) by partitioning each page with 16 selected column addresses
   b. Perform a ‘read status’ after each ‘partial page program’ operation
   c. Identify the address location of each error detected
   d. Using 55h data, perform ‘partial page program’ operations on all blocks (good or bad) by partitioning each page with 16 selected column addresses
   e. Perform a ‘read status’ after each ‘partial page program’ operation
   f. Identify the address location of each error detected
   g. Erase all blocks

Program 8—Read Disturb Testing
   a. To be performed on both good blocks and known bad blocks
   b. Erase the device
   c. Perform 50k, 100k, 500k, 1m ‘page read’ operations on a single page
   d. Identify the address location of each error detected
   e. Erase the device

Experimental Results

Bad Block Testing: Prior to testing the Micron 2Gb parts, recent historical data on the related Micron 4Gb device was analyzed [Heidecker]. The 4Gb and 2Gb share the same data sheet, and therefore, the same common technology and design practices. There was also a larger sample size of 4Gb compared to the 2Gb (128 4Gb vs. 12 2Gb devices).

Approximately 14% of the 4Gb devices had zero bad blocks, and 25% of the 2Gb devices (3 out of 12) had zero bad blocks. The 2Gb devices had a higher percentage (almost 2X) of bad blocks when compared to the larger 4Gb device.

One would expect the opposite to be true in terms of number of defects. The 4Gb device is roughly twice the size of the 2Gb, and therefore should have a 30%–40% reduction in the number of good die using the standard Murphy yield formula [Stapper] of \( Y = e^{-AD} \) where A is the device area and D is the defect density. These data are shown in Figure 9 for the 4Gb devices and Figure 10 for the 2G devices. Fourteen (14%) of the 4Gb devices have no bad blocks. Block size on these devices is 64 pages or 128K + 4K bytes. The 4Gb device has 4,096 blocks. One bad block represents approximately 0.02% of the die. Figure 9 represents a total of 128 4Gb devices that were tested.
Figure 9 shows that having one bad block is the highest populated category. This result is not repeated in the 2Gb devices shown in Figure 10. For the 2Gb parts, the highest population categories were either zero bad blocks or three bad blocks per device. The population curve envelope that can be drawn over the 4Gb data in Figure 9 is indicative of either a skewed Gaussian or perhaps a lognormal distribution. Given the sparse nature of the data in Figure 10, no practical envelope can be drawn.
As the 2Gb devices were being prepared for the next test, the bad block information was double-checked. During this testing, it was determined that none of the 12 devices had repeatable bad block locations when compared to their initial bad block table (Table 2).

Table 2. Initial Bad Block Table

<table>
<thead>
<tr>
<th>Device #</th>
<th>Bad Block Location</th>
</tr>
</thead>
<tbody>
<tr>
<td>1</td>
<td>242 347 775 1230 1652 3057 3511</td>
</tr>
<tr>
<td>2</td>
<td>235 604 711 1107 1206 1626 2563 3062 3077 3475</td>
</tr>
<tr>
<td>3</td>
<td>654 1430 2603</td>
</tr>
<tr>
<td>4</td>
<td>7 2025 3463</td>
</tr>
<tr>
<td>5</td>
<td>8 1502 2775</td>
</tr>
<tr>
<td>6</td>
<td>9 130 304 430 1311 1742 2444 3167 3624 3721</td>
</tr>
<tr>
<td>7</td>
<td>10 134 717 772 1771 2136 3570</td>
</tr>
<tr>
<td>8</td>
<td>11 325 2137 3656</td>
</tr>
<tr>
<td>9</td>
<td>12 156</td>
</tr>
</tbody>
</table>

More of the bad blocks are in the lower logical addresses than the higher logical addresses. Figure 11 illustrates the distribution of bad blocks by logical address. The smallest logical address locations (0–500) show the highest number of bad blocks. The remaining frequency of logical addresses is more or less uniformly distributed.

Figure 11. Frequency of Occurrence of Initial Bad Blocks by Logical Address
The failure of the bad block table to remain consistent and repeatable put the entire experimental plan at risk. The main hypothesis to be proven or disproved was based on the assumption that a bad block contained a hard error. This hard error site was to be exploited as a means to increase the possibility of inducing a disturb failure in a nearby good site. The quality of the entire die is now at question. To address this die quality issue, the following test sequence was developed and implemented. This test sequence is designed to evaluate the data retention performance of the devices to both logical states.

**Date Retention Testing:** The data retention test sequence is listed below and the results are shown in Table 3:

1. Block erase (and read array)
2. Bake 48 hours, 150°C
3. Read array for any errors
4. Page program all 0s (and read array)
5. Bake 48 hours, 150°C
6. Read array for any errors

<table>
<thead>
<tr>
<th>Part Number</th>
<th>Initial Read (Number of Bad Blocks)</th>
<th>Erase (FF)</th>
<th>Bake 48hr/150°C</th>
<th>Read</th>
<th>Page Program (00)</th>
<th>Read</th>
<th>Bake 48hr/150°C</th>
<th>Read</th>
<th>Bake 96hr/150°C</th>
<th>Read</th>
</tr>
</thead>
<tbody>
<tr>
<td>1</td>
<td>7</td>
<td>0</td>
<td>0</td>
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<td>3 new</td>
<td>5 new 3 same</td>
<td>3 new 3 same</td>
<td>3 new 3 same</td>
<td>3 new 3 same</td>
<td></td>
</tr>
<tr>
<td>10</td>
<td>6</td>
<td>1 new</td>
<td>1 new</td>
<td>1 new</td>
<td>1 new same</td>
<td>1 new same</td>
<td>1 new same</td>
<td>1 new same</td>
<td>1 new same</td>
<td></td>
</tr>
<tr>
<td>11</td>
<td>3</td>
<td>0</td>
<td>0</td>
<td>0</td>
<td>1 new</td>
<td>3 new 1 same</td>
<td>3 new 1 same</td>
<td>3 new 1 same</td>
<td>3 new 1 same</td>
<td></td>
</tr>
<tr>
<td>12</td>
<td>1</td>
<td>0</td>
<td>0</td>
<td>0</td>
<td>3 new</td>
<td>5 new 3 same</td>
<td>5 new 3 same</td>
<td>5 new 3 same</td>
<td>5 new 3 same</td>
<td></td>
</tr>
</tbody>
</table>

Table 3 should be read left to right in terms of the time sequence of the occurrence of events. The term “new” means a new logical failure site was noted. The term “same” means that the same failure site continued to fail at the next read point. There are several important results that can be obtained from the data in Table 3.
1. The initial bad block information is totally non-repeatable after first erase and bake.
2. The initial number of bad blocks does not correlate to the number of retention failures seen as a function of increasing time at temperature.
3. 33% of the population experienced retention failures while the remaining 66% did not experience any retention failures during testing.
4. These data do not match Micron’s qualification and reliability data for the 2Gb device [Micron Q&R]. Data retention bake results published in the Micron reference show 0 failures out of 237 parts baked at 150°C for up to 1008 hours. Micron reports this is an equivalent FIT rate of 24 FITS at 50°C. The 33% failures in 192 hours of testing reported in this paper are an equivalent of 2,621 FITs at 50°C. This is a 100X larger FIT rate than the standard parts listed in the Micron Q&R documents.
5. These data retention failures appear to be hard failures.
6. Figure 12 shows the increasing number of bad block failures with increasing retention bake time. The number of bad blocks continues to increase with increasing time at elevated temperature.

![Figure 12. Total Number of Bad Blocks vs. Retention Bake Time.](image)

At this point in the experiment, the entire population of 2Gb parts is considered suspect. No physical failure analysis was performed on these parts to possibly determine the root cause of the
data retention failures. One possible suggestion to explain the results is that the parts may have either missed entirely or only received a partial final burn-in and test by the manufacturer. The parts were subjected to continued electrical testing to fully characterize their electrical performance. This includes voltage corner testing as well as the originally designed disturb testing. Voltage corner testing was performed on all parts as means to try to understand the retention and bad block results.

*Voltage Corner Testing:* Voltage corner testing is a combination of programming and erasing followed by a read. This testing is performed at a mix of high and low voltages. This combination is also performed at room and high temperature. The steps of voltage corner testing are listed in Table 4. This test matrix was performed at 25°C and 90°C.

*Table 4. Voltage Corner Test Matrix*

<table>
<thead>
<tr>
<th>Function</th>
<th>Voltage</th>
</tr>
</thead>
<tbody>
<tr>
<td>Block erase</td>
<td>2.85V</td>
</tr>
<tr>
<td>Read all FF</td>
<td>2.85V</td>
</tr>
<tr>
<td>Read all FF</td>
<td>3.75V</td>
</tr>
<tr>
<td>Program all 0s</td>
<td>2.85V</td>
</tr>
<tr>
<td>Read all FF</td>
<td>2.85V</td>
</tr>
<tr>
<td>Read all FF</td>
<td>3.75V</td>
</tr>
<tr>
<td>Block erase</td>
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</tr>
<tr>
<td>Read all FF</td>
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</tr>
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<td>Read all FF</td>
<td>3.75V</td>
</tr>
<tr>
<td>Program all 0s</td>
<td>3.75V</td>
</tr>
<tr>
<td>Read all 0s</td>
<td>2.85V</td>
</tr>
<tr>
<td>Read all 0s</td>
<td>3.75V</td>
</tr>
</tbody>
</table>
Both device 3 and device 10 each had one bit location fail the read 0s testing at all voltages. These bits failed at both 25°C and 90°C tests. All other devices passed. The failing bit locations were the same locations that had failed in the previously discussed retention and bad block experiments. These sites are stuck-at-1 faults. This means the erase command is not completely removing all the charge on the floating gate of the failing cells.

The disturb testing was divided into program disturb and read disturb. A program disturb occurs when one or more bits not intended to be programmed are changed from a “1” to a “0” during a program operation. Increasing the number of partial page program operations has been shown to exacerbate these types of errors [Micron Flash Application]. Program disturb errors can show up on pages being programmed or on other pages within the same block.

Read disturb errors occur when one or more bits are changed from “1” to “0” during a read operation. Read disturb errors occur within the block being read, but on a page or pages other than the particular page being read. Performing a high number of read operations can increase the possibility of read disturb errors. The number of read operations needs to be quite large however. As listed in Program 8, page read operations were 50K, 100K, 500K, and 1M operations on a single page.

No program disturb or read disturb failures were detected.

**Conclusions**

This experiment was designed to evaluate disturb errors on 2Gb NAND Flash devices. No disturb errors were measured. However, the devices showed inconsistent bad block performance and retention behavior. This behavior is concerning and could possibly adversely impact reliability performance of these devices. It is recommended that all COTS flash devices targeted for NASA missions be individually screened and characterized before being accepted for use.
References


Heidecker, J., Internal JPL e-mail, September 2007.


